

**B.E. ELECTRONICS AND TELE-COMMUNICATION ENGINEERING
FOURTH YEAR SECOND SEMESTER EXAM, 2025**

ADVANCED ELECTRON DEVICES

Time: 3 hours

Full Marks: 100

(All parts of the same question must be answered together)

PART-I (60)

Answer Any Three (3×20=60)

1. Explain VCA for compound semiconductors. Explain the origin of bowing factor. If band gap of Si and Ge are 1.2 eV and 0.7 eV, respectively, calculate the bandgap of $\text{Si}_{0.8}\text{Ge}_{0.2}$ with $b=0.1$. [4+2+4]
2. Explain the growth of heterostructures using Knudsen cell in Molecular Beam Epitaxy (MBE). [10]
3. What is Built-in Strain in Heterostructures? Explain tensile and compressive strain. [4+6]
4. What are the different types of metal semiconductor junction. Explain with energy band diagram for both p and n-type semiconductors. [2+8]
5. Write a short note on resonant tunneling diode (RTD). [10]
6. Explain quantum confinement in low dimensional structures. Explain Frenkel excitons and Wannier-Mott excitons. [4+6]

Answer Any Four (4×15=60)

7. Write advantages of HBT over BJT. Draw the schematic and explain the working. Explain the energy band diagram for active region of operation. [4+6+5]
8. Define Quantum Efficiency and Responsivity of photodetectors. Classify photodiodes. Draw and explain the working of p-n photodiodes and its characteristics. [4+3+8]
9. Define density of states. Derive DOS in an infinite potential quantum well. Determine electron concentration n_s in a 2D GaAs system at $T=300\text{K}$ when $E_F - E_C = 0.15\text{eV}$. [2+6+7]

[Turn over

Ref. No.: Ex/ET/PC/B/T/424/D/2025

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10. What are the different types of heterojunctions. Explain with energy band diagrams. [3+9+3]
Give examples.
11. Draw and explain the energy band diagram of AlGaAs/GaAs heterostructure in thermal [10+5]
equilibrium. $\chi_{\text{AlGaAs}}=3.77$ eV, $\chi_{\text{GaAs}}=4.07$ eV, $E_{\text{gAlGaAs}}=1.82$ eV, $E_{\text{gGaAs}}=1.42$ eV.
AlGaAs is doped to n-type whereas GaAs is p-type. $(E_{\text{C}}-E_{\text{F}})_{\text{AlGaAs}}=0.1$ eV and $(E_{\text{F}}-E_{\text{V}})_{\text{GaAs}}=0.12$ eV. Label the energy band diagram.
12. What is MQW. Explain the formation of MQW. What are the differences between [2+4+5+
super lattice and MQW. Mention few applications of super lattice and MQW. 4]
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